



Development, characterization, and application of compliant intracortical implants

Kagithiri Srikantharajah

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Contents

Abbreviations	xiv
1. Introduction	1
2. Fundamentals	3
2.1. Neural interfaces	3
2.1.1. Essential features for implant development	3
2.1.2. Intracortical implants	5
2.1.3. Compliant interfaces	6
2.2. Neurophysiology	7
2.2.1. Electrogenic cells	8
2.2.2. Neural activity in the brain	10
2.2.3. Recording electrogenic activity	11
2.2.4. Neuron/electrode interface	12
3. Methods	15
3.1. Optical characterization	15
3.2. Electrical characterization	15
3.2.1. Electrochemical impedance spectroscopy	16
3.2.2. Cyclic voltammetry	17
3.3. Atomic force microscopy	17
3.4. Brain slice experiments	18
3.4.1. Tissue preparation	18
3.4.2. Experimental setup	18
3.4.3. Data acquisition	19
3.5. Acute <i>in vivo</i> experiments	19
3.5.1. Animal surgery	19
3.5.2. Sensory stimulation	20
3.5.3. <i>In vivo</i> electrophysiology	20
3.5.4. Data analysis	20
3.5.5. Histology	21
4. Fabrication of compliant intracortical implants	23
4.1. Polymer choices	23
4.2. Design considerations	25
4.3. Microfabrication of organic electrodes	26

Contents

4.4.	ParyleneC based electrode array fabrication	29
4.4.1.	Single-metal-layer process	29
4.4.2.	Double-metal-layer process	31
4.4.3.	Fabrication considerations	33
4.5.	Flexible intracortical implants	37
4.6.	Conclusion	41
5.	PEDOT:PSS as electrode coating material	43
5.1.	Conducting polymer PEDOT:PSS	44
5.2.	Experimental section	45
5.2.1.	Electrochemical deposition	46
5.2.2.	Spin-coating	46
5.2.3.	Iridium oxide as adhesion layer	46
5.2.4.	Characterization	47
5.2.5.	Statistical analysis	48
5.3.	Spin-coated and electrochemically deposited PEDOT:PSS films	49
5.3.1.	Fabrication challenges of spin-coated PEDOT:PSS	49
5.3.2.	Coating morphology and thickness	51
5.3.3.	Electrochemical performance	53
5.3.4.	Abiotic stability	60
5.3.5.	Electrochemical stability	65
5.4.	Conclusion	72
6.	Shuttle system for implantation of flexible probes	75
6.1.	Insertion mechanisms	76
6.2.	Biodegradable polymers	76
6.3.	Development of a tissue-friendly insertion system	79
6.3.1.	Reduction of effective length	79
6.3.2.	Manual coating approach	80
6.3.3.	Insertion test	82
6.3.4.	Towards a wafer-scale shuttle system	84
6.4.	Conclusion	88
7.	Application of compliant intracortical probes	89
7.1.	Brain slice experiments	90
7.1.1.	Experimental section	90
7.1.2.	Slice recordings	91
7.2.	Acute <i>in vivo</i> validation	94
7.2.1.	Experimental section	94
7.2.2.	In vivo electrophysiology	95
7.3.	Conclusion	99
8.	Summary and outlook	101

A. Appendix	105
A.1. Fabrication protocol of PaC based single-metal-layer devices	105
A.2. Fabrication protocol of PaC based double-metal-layer devices	107
A.3. Soldering flexible probes to PCBs	110
A.4. PDMS based electrode array fabrication	110
A.4.1. Microfabrication	110
A.4.2. Ultra-flexible intracortical probes	114
A.5. Fabrication of PEDOT:PSS coated probes	115
A.6. Introducing iridium oxide as adhesion layer	116
A.7. Sample holder for accelerated ageing test	117
A.8. PEDOT:PSS as electrode coating material	118
A.8.1. Platinum microelectrodes	118
A.8.2. Electrochemical deposited PEDOT:PSS	118
A.8.3. Spin-coated PEDOT:PSS	121
A.8.4. Overview of electrochemical parameters	122
A.8.5. IrOx as adhesion promoter	123
A.9. PEG based insertion aid - Manual coating process	125
A.10. Crystallization of PEG	126
A.11. Agarose gel	126
A.11.1. Preparation of agarose gels	126
A.11.2. Mechanical characterization of agarose gels	127
A.12. PEG based insertion aid: Wafer-scale approach - PDMS mold	128
A.13. Type of intracortical implants	129
References	155
Acknowledgements	xv
Own Publications	xvii

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